

## Sensor R&D Status and Plans

# G. Bolla For the Sensor working group. ມີPັເປກເປັນເກຣ





Overview of the ongoing R&D (mostly from last Sensor WG meeting)

- Lorentz angle studies
- Latest results on MCZ sensors (SiBT)

**Outline** 

- Calibration of testing setups
- Precision capacitance measurements on Pixel sensors
- 3D sensors development

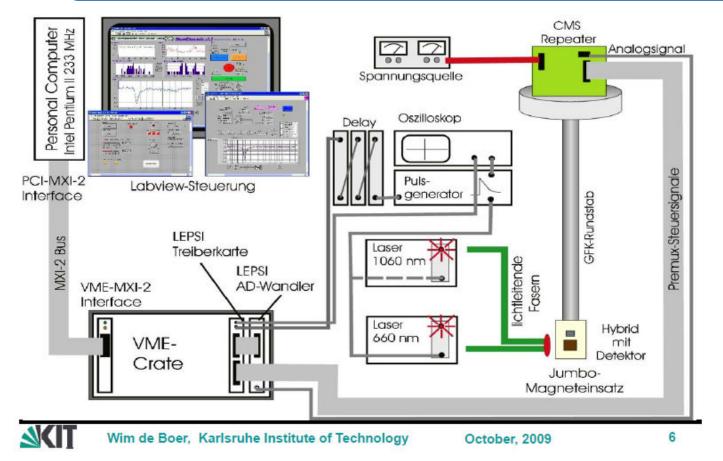
Central European Consortium will present their recent results

Discussion on HPK submission Marcello (Status) Frank (Plans)



#### **Lorentz angle studies**

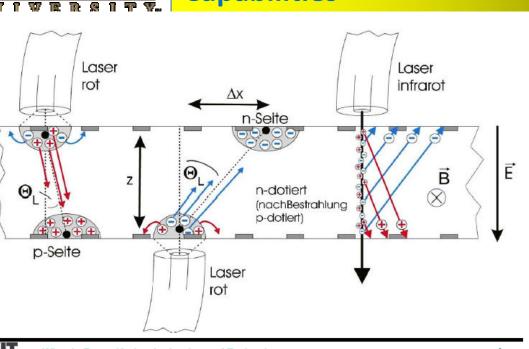




Measured real CMS ministrip sensors (instead of ministrips from HERA-B, which had smaller pitch) CMS sensors allowed to measure to much higher bias voltages, use 500 um for better sensitivity

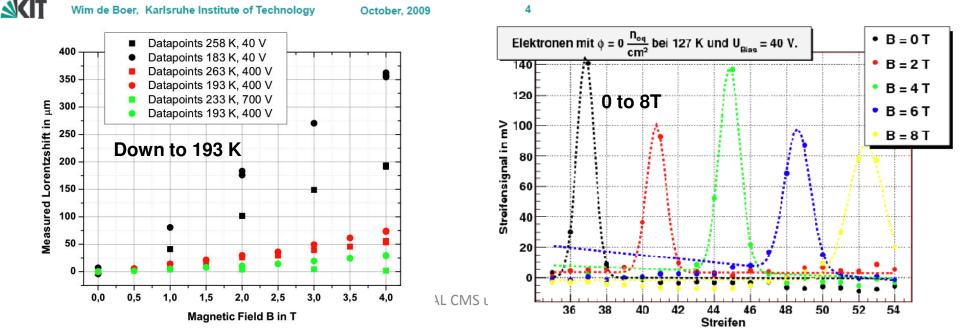
- Measured RD50 n-in-p sensors to get much better Lorentz angle measurements for electrons
- Measure Lorentz angle in highly irradiation sensors





The setup allows for measurements of holes/electrons Lorentz angle. At different voltages and at different temperatures.

Sensors are readout through PreMux (=APV w.o. Pipeline) on hybrid.







### Parametrization of Lorentz angle model

## An Algorithm for calculating the Lorentz angle in silicon detectors.

V. Bartsch, W. de Boer, J. Bol, A. Dierlamm, E. Grigoriev, F. Hauler, S. Heising, L. Jungermann. Nucl.Instrum.Meth.A497:389-396,2003. e-Print: physics/0204078

$$E(z) = \frac{U_{Bias} - U_{Dep}}{d} + 2\frac{U_{Dep}}{d}\left(1 - \frac{z}{d}\right)$$

Model

mobility

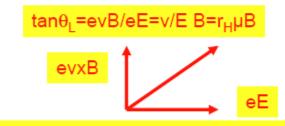
$$\mu = \frac{\mu_0}{\left(1 + \left(\frac{E\mu_0}{v_s}\right)^\beta\right)}$$

electrons  

$$\mu_0 = 1417 \frac{cm^2}{VS} (T/300K)^{-1.76 \pm 0.08}$$
  
 $\beta = (1.247 \pm 0.054)$ 

$$v_{sat} = 1.0 \cdot 10^7 \frac{cm}{s} (T/300K)^{\frac{0.89\pm0.10}{s}}$$

Wim de Boer, Karlsruhe Institute of Technology



r<sub>H</sub>=Hall factor, depends on scattering mechanism

#### New fit of the 3 parameters:

- shaping exponent β
- temperature exponents

holes  

$$\mu_0 = 470.5 \frac{cm^2}{VS} (T/300K)^{-2.60\pm0.03}$$

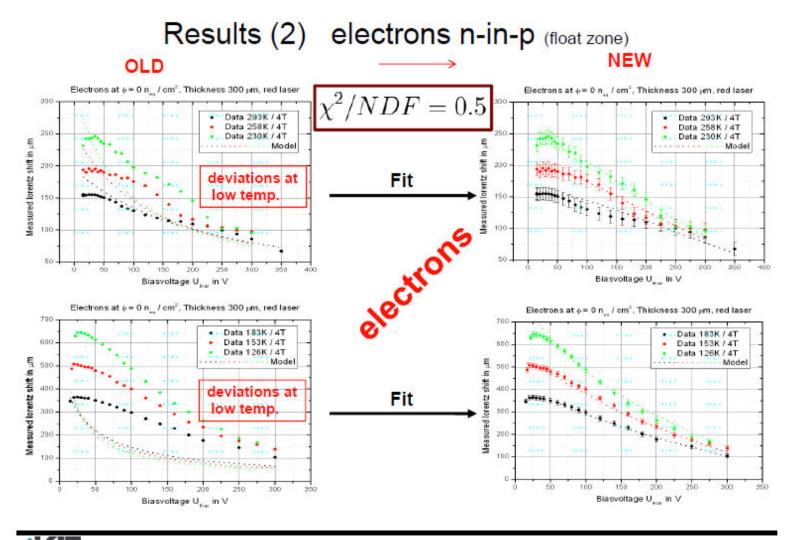
$$\beta = (1.383 \pm 0.052) (T/300K)^{0.07\pm0.05}$$

$$v_{sat} = 8.37 \cdot 10^6 \frac{cm}{s}$$

#### October, 2009







Wim de Boer, Karlsruhe Institute of Technology

October, 2009

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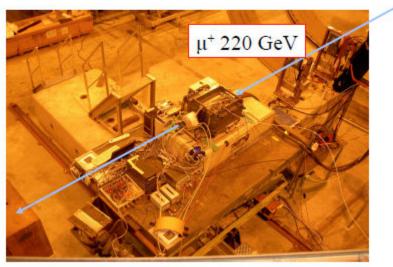


#### SiBT and MCZ sensors (Jaakko)



## How Si detector R&D is done at H2 test beam ?

- CMS based read-out electronics (APV25) and DAQ
- 8 detector planes providing reference tracks for DUT
- Measurement down to -50°C
- 50 000 events in about 15min
- Effective area 4cm × 4cm
- Telescope resolution ~4µm
- Detectors under test processed at Microelectronics Center of Helsinki University of Technology
- Irradiation at Univ. Karlsruhe, 26 MeV protons



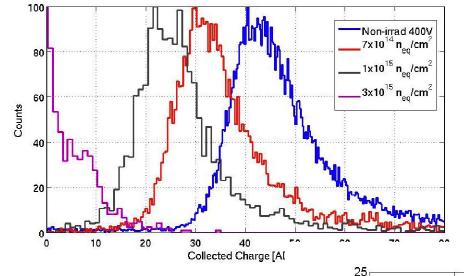


28/09/09 Jaakko Härkönen, Upgrade Sensor Working Group



#### e- and h+ charge collection

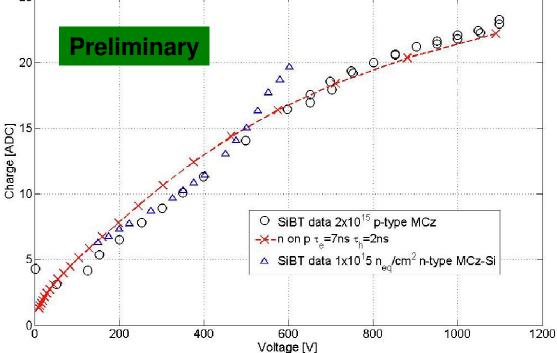




#### N-type MCZ

Hard to find a Landau after 3E15 fluence.

When Collecting electrons there is a factor of two in fluence (given the same charge collected).







### Summary of test beam period 28.06.-13.07.2009

- > 1Tb High quality data was taken.
- Several different novel detectors were measured, including CID, 3D, thin MCz-Si, p on n structures etc.
- The comprehensive off-line data analysis will take several months. Results will be reported in RD39 and RD50 Workshops and CMS Tracker Upgrade meetings.
- Preliminary results show nice coincidence with classical models for p and n-type MCz-Si both.
- Increase of CMS TK Up Si sensor R&D test beam activity is foreseen in coming years







## calibration program

Karlsruhe measured several non-irradiated former CMS teststructures (HPK 300µm)

### Participants:

- Desy 15.07
- Florence 1.09
- Hamburg 15.07
- Louvain 15.07
- Pisa 1.09
- Rochester 1.08
- Vienna 15.07

#### some parameters and settings:

- measurement to be done at room temperature (21°C) and relative humidity < 30%</li>
- frequencies for capacitance measurements:
  - CV 1kHz
  - CC 100Hz
  - Cint 1MHz
- all strip measurements at Vbias = 600V

http://www-ekp.physik.uni-karlsruhe.de/~hartmann/Calibration\_and\_final\_measurement.3.doc



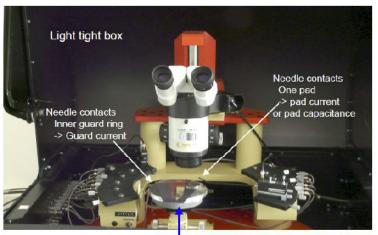
Time per strip [55 s] **Results** 



**SKIT** Minisensor strip measurements Rochester results [Karlsruhe] Hamburg Vienna Louvain Desy Rpoly [MOhm] [ 1,41 - 1,49 ] 1,51 1,43 1,43 1,44 21 - 72 73,1 CouplCap[pF] [ 68,0 - 69,6 ] 69,4 69,4 80,3 Rint [Gohm] [ > 5 ] > 40 > 4 above limit Cint [pF] [0,63 - 0,66 ] 0,71 0,64 - 1,2 0,68 lleak [pA] [< 120 ] < 26 mean ~ 60 < 12 < 1000 Pinhole [pA] < 389 ] < 1 no current measured ~ 25 min ~ 35 min







Backplane contacted via Al table ( '+' of high voltage)\_



grade workshop







## Conclusion II



- we achieved comparable results for most measurements
- we found some issues to be improved
- so far we did no voltage scans on single strips => next round!
- switching between the single measurements has to be automatic in order to cope with the huge number of sensors (strips) to be qualified. Time varied between 1 and 35 min per strip.
- cold chucks need to be installed in order to measure irradiated halfmoons

## Plans:

4 irradiated halfmoons are in Karlsruhe, but need to be measured. Will be ready for shippment by 19<sup>th</sup> of October.

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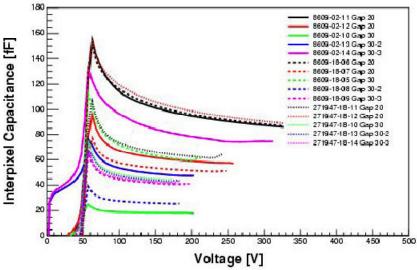
**Pixel capacitances** 

#### Capacitance measurements of CMS pixel barrel

sensors

T. Rohe<sup>1</sup>, F. Bechtel<sup>2</sup>, V. Radicci<sup>3</sup>, J.Sibille<sup>1,3</sup>

<sup>1</sup> Paul Scherrer Institut <sup>2</sup> University of Hamburg <sup>3</sup> University of Kansas

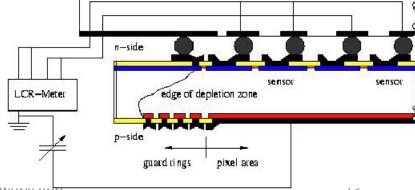


Inter pixel capacitance in bias dependent and saturates about 300-350V

- Increasing the gap from 20 to 30 mm results in a drop of C(150V)  ${\sim}100$  to 70 fF

- Large fluctuations and some outliers
- more statistics
- check dependence on technology parameters (mainly p-spray dose)

1 pixel surrounded by 8 neighbours Gap





#### Major accomplishments

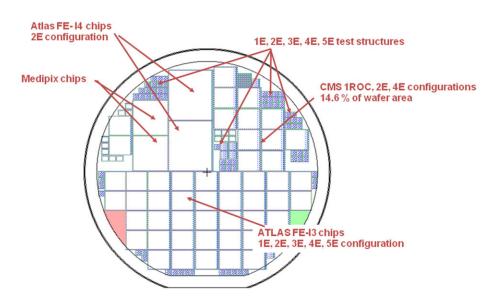
- We have collaborated with groups in ATLAS and MEDIPIX and funded a run of 3D sensors with SINTEF.
- 2. The layout of the wafer is shown in Fig 1.
  - 1. Two sensors matching the PSI46 ROC with 2 and 4 columns (CMS-2E and CMS-4E).

**3D Sensors** 

- 3. We have performed simulations of CMS-2E and CMS-4E sensors before and after irradiation.
- 4. Successful fabrication of the devices at SINTEF
- 5. Measurements of several devices were done at SINTEF (I-V curves).
  - 1. Test metal for electrical measurement was deposited on the devices to short circuit all n-electrodes. This test metal layer was then removed and replaced by the final metallization.
- 6. Two wafers were sent to IZM for bumbonding the good devices to PSI46 ROCs.

#### Proposal from Purdue and FNAL

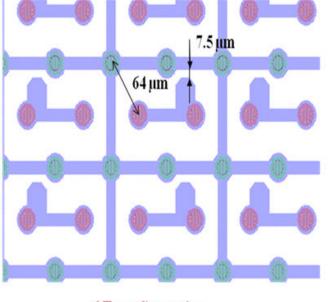
Strong collaboration with industrial partner (Sintef) to produce cutting edge devices for the pixel innermost layer/s

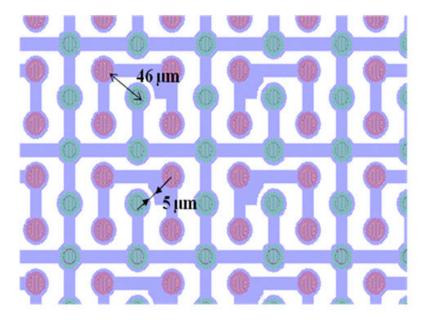




### **3D Sensors: pixel details**







2E configuration

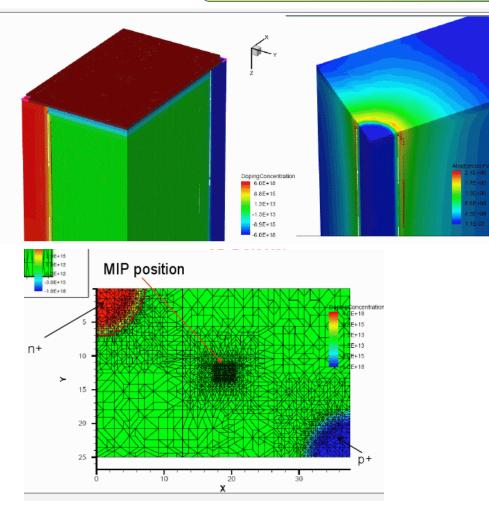
**4E configuration** 

- 1. 2 and 4 column pixels
  - 1. Different distance between n+ and p+ electrode
- 2. Not possible to implement a bias GRID
  - 1. Need for a temporary metallization to short all the pixel together
    - 1. To be replaced before bumping.
- 3. Devices are were simulated with Sentaurus (O. Koybasi, Purdue)

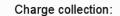


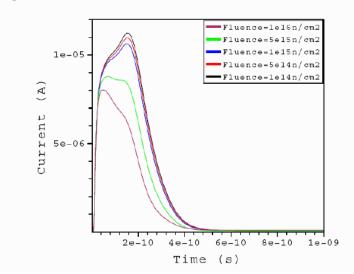
#### **3D Sensors: simulations**



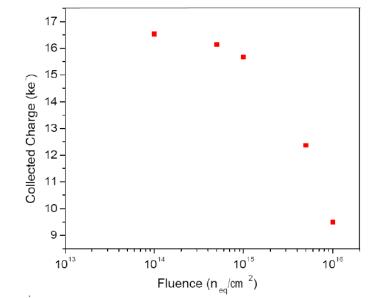


#### CCE versus radiation damage.





#### Charge Collection Efficiency:

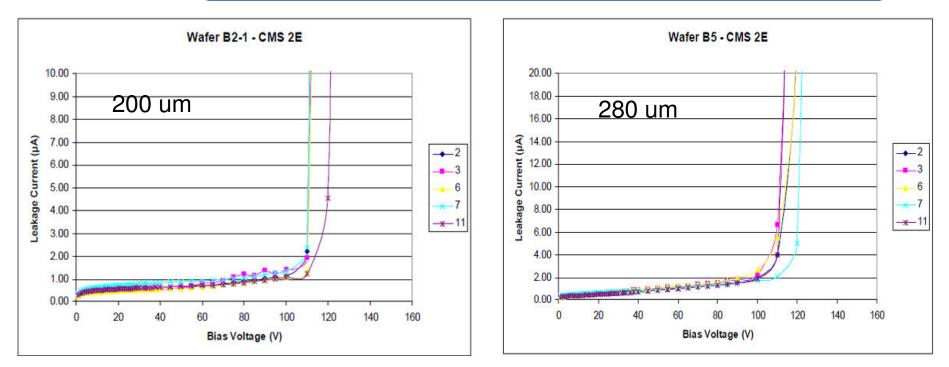


G. Bolla, FNAL CMS upgrade



#### **3D Sensors: IV characteristics**



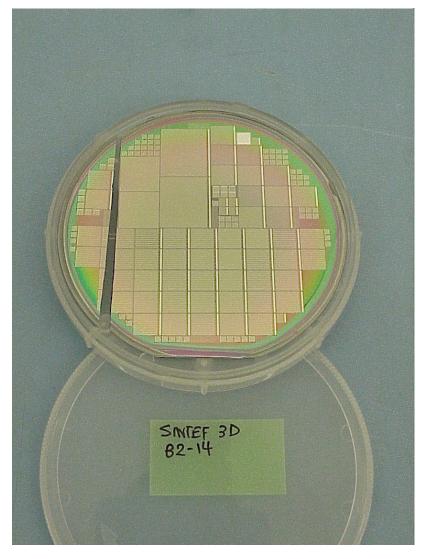


- 1. Leakage current in the order of 1 uA/cm<sup>2</sup> before breakdown (100 nA/cm<sup>2</sup> at Vdep)
  - 1. There is a theory that some of this current might be due to the temporary metal layer
    - 1. To be verified after bumping
- 2. Depletion voltage around 15-20 V



### **3D Sensors: bumping**





- 1. Two wafers sent to IZM for bumping
  - 1. PSI46 ROC ready since production of FPIX
- 2. Total of 15 good sensors (out of 22)
- 3. One wafer was broken during shipping
  - 1. CMS devices not affected but wafer alignment marks are now in two different pieces
- 4. 2 more wafers from Sintef are now ready to go to IZM
- 5. We expect bumped sensors back from IZM within the calendar year
- 6. Plan:
  - 1. Characterize them at Purdue (IV)
  - 2. Mount them on readout boards and get them in the FNAL test-beam



# CMS

- Order finally placed ~ February
  - Central European Consortium, CERN, INFN, PSI, US
- Detailed specs agreed
  - Wafer procurement Done
- Wafer Layout finalized
  - Later from Marcello
- Testing and irradiation program
  - Later from Frank
- Now a presentation from CEC.